

 <p style="text-align: center;"><b>INFORMATION DISCLOSURE CITATION</b> (Use several sheets if necessary)</p>	Docket Number (Optional) <b>SWO-0002</b>	Application Number <b>10/705,591</b>
	Applicant(s) <b>Jeong-hwan LEE, et al.</b>	
	Filing Date <b>11-10-2003</b>	Group Art Unit <b>2875</b>

**U.S. PATENT DOCUMENTS**

EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

**U.S. PATENT APPLICATION PUBLICATIONS**

EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

**FOREIGN PATENT DOCUMENTS**

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
JMH		2001-166306	6-22-2001	JAPAN w/English abstract				✓
JMH		2003-84110	3-19-2003	JAPAN w/English abstract				✓
JMH		2001-83507	3-30-2001	JAPAN w/English abstract				✓

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER /Jason Han/ (09/18/2006)	DATE CONSIDERED 09/18/2006
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.